

INFORMATION DISCLOSURE CITATION
(Use several sheets if necessary)

Docket Number (Optional)
WLJ.075

Application Number
09/914,204

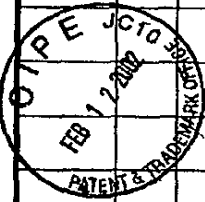
Applicant(s)
John MACNEIL

Filing Date
08/23/01

Group Art Unit
UNKNOWN

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
ET	A	4,894,254	01/16/90	NAKAYAMA et al.	427	539	—
ET	B	4,822,632	04/18/89	WILLIAMS et al.	427	536	—
ET	C	4,096,315	06/20/78	KUBACKI	428	412	—



FOREIGN PATENT DOCUMENTS

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
ET	D	WO 98/08249	02/26/98	PCT	—	—	✓	
ET	E	WO 94/01885	01/20/94	PCT	—	—	✓	

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

EXAMINER **ETsoy**

DATE CONSIDERED **12/2/03**

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

INFORMATION DISCLOSURE CITATION (Use several sheets if necessary)				ATTY DOCKET NO. WLJ.075		SERIAL NO. 09/914,204		
				John MacNeil		GROUP UNKNOWN		
				FILING 08/23/2001				
U.S. PATENT DOCUMENTS								
*EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
ET	A	3,223,040	12/14/1965	DINKELKAMP	427	5	—	
ET	B	4,793,524	12/27/1988	STARR	222	309	—	
ET	C	5,095,938	03/17/1992	GARRISON	427	1700	—	
ET	D	5,098,741	03/24/1992	NOLET ET AL.	427	248.1	—	
ET	E	5,195,655	03/23/1993	BUKHMANN	222	15	—	
ET	F	5,273,851	12/28/1993	TAKEI ET AL.	430	68	—	
ET	G	5,314,724	05/24/1994	TSUKUNE ET AL.	427	3/89	—	
ET	H	5,356,034	10/18/1994	SCHLUMBERGER	222	61	—	
ET	I	5,494,712	02/27/1996	HU ET AL.	427	489	—	
ET	J	5,534,069	07/09/1996	KUWABARA ET AL.	118	719	—	
ET	K	5,593,741	01/14/1997	IKEDA	427	579	—	
FOREIGN PATENT DOCUMENTS								
		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO
ET	L	GB 2 280 169 A	01/25/1995	UNITED KINGDOM	—	—	✓	
ET	M	GB 2 220 869 A	01/24/1990	UNITED KINGDOM	—	—	✓	
ET	N	GB 2 111 064 A	06/29/1983	UNITED KINGDOM	—	—	✓	
ET	O	GB 2 108 133 A	05/11/1983	UNITED KINGDOM	—	—	✓	
ET	P	EP 0 529 334 A2	03/03/1993	EPO	—	—	✓	
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)								
	Q	Kamiya Kazuo, "Production of Silicon Dioxide Coating," Patent Abstracts of Japan, Publication No. 10310866, Publication Date 24-11-98						
	R	A. Grill et al, "Low dielectric constant films prepared by plasma-enhanced chemical vapor deposition from tetramethylsilane," Journal of Applied Physics, Volume 85, Number 6, 15 March 1999, pages 3314-3318.						
EXAMINER <i>ET 509</i>				DATE CONSIDERED <i>12/2/03</i>				
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U.S. PATENT DOCUMENTS

*EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
ET	S	5,876,503	03/02/1999	ROEDER ET AL.	118	726	RECEIVED
ET	T	5,620,524	04/15/1997	FAN ET AL.	118	726	JUL 26 2002
ET	U	5,641,559	06/24/1997	NAMIKI	428	216	TC 1700
ET	V	5,730,804	03/24/1998	GOMI ET AL.	118	726	1 RECEIVED
ET	W	5,786,039	07/28/1998	BROUQUET	427	528	RECEIVED

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO
ET	X	EP 0 254 205 A2	01/27/1998	EPO			✓	
ET	Y	EP 0 726 599 A2	08/14/1996	EPO			✓	
ET	Z	EP 0 212 691	03/04/1987	EPO			✓	
ET	AA	EP 0 826 791 A2	03/04/1998	EPO			✓	
ET	BB	WO 98/23787	06/01/1998	EPO			✓	

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

EXAMINER

ET 304

DATE CONSIDERED

12/2/03

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INFORMATION DISCLOSURE CITATION
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Docket Number (Optional)	Application Number
W 0075	09/914,204
Applicant(s) John MACNEIL et al.	
Filing Date	Group Art Unit
February 20, 2002	2812

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
ET	A	6,028,015	02/22/2000	WANG et al.	438	789	—

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JUL 29 2002
TECHNOLOGY CENTER 2800

FOREIGN PATENT DOCUMENTS

REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO

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JUL 6 2002
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OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

EXAMINER ET soy	DATE CONSIDERED 12/2/03
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WLJ.075

NEW

John MACNEIL et al.

Filing Date

AUGUST 23, 2001

09/914204

Group Art Unit

TO BE ASSIGNED

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12/02/03

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